#### **The Three Principle Soft X-ray Spectroscopies**



#### Photoemission spectroscopy: experimental system



## Terminology of Photoemission Spectroscopy

**XPS:** x-ray photoelectron spectroscopy. Used to determine binding energies of core-levels. These binding energies shift with chemical state (chemical-shift).

**UPS:** ultra-violet photoelectron spectroscopy. Used to measure binding energies of valence orbitals.

**ARPES:** angle-resolved photoemission spectroscopy. Measures the intensity of valence band features as a function of emission angle, which can be used to determine band-structure.

**XPD:** x-ray photoelectron diffraction. Measures the intensity of core-level features as a function of emission angle, which can be used to determine surface structure.

# Basic model of photoemission physics



## Energy conservation: measure binding energies



#### **A typical X-ray Photoelectron Spectrum**



#### The inelastic mean-free-path for an electron: Physical origin of surface sensitivity in electron spectroscopy



The minimum in the mean-free-path is as small as a single atomic layer.

Variable surface sensitivity by tunable photon energy: Case of pyrite (FeS<sub>2</sub>)



# X-ray Photoelectron Diffraction (XPD)

- A powerful tool for determining the atomic structure of surfaces
- Precision of bond-length measurement is about 0.02 Angstrom
- Source of electrons is known: determined by XPS binding energy
- Theory is a multiple-scattering theory; certain experimental conditions permit a single-scattering interpretation
- Has been used as a form of quantum holography: direct data inversion



# **Experimental XPD Patterns**



XPD of Mn/Ni, ESCA (MgK<sub> $\alpha$ </sub>, hv=1253.6 eV)



#### An XPD Diffraction "Volume" Cu(100)



#### XPD for surface structure determination: The case of Si(100)c4x2



S1-XPD (left) and MS simulations (right) at hv=140 and 160 eV. Dimer atoms only (Atom 1)



## Si(100)c4x2: Dimers and Substrate

**Fig.4**  $S_1$ -XPD (left) and MS simulations (right) at hv=140 and 160 eV. Emitters are dimer atoms at upper positions labeled as ATOM 1. In this figure, we only show the comparison at two energies.





**Fig.5**  $S_4$ -XPD (left) and MS simulations (right) at hv=145 and 160 eV. Emitters are those silicon atoms in the second layer substrate labeled as ATOM 4.

Photoelectron Holography: Analogy to Optical Holography



**Photo-electron Holography** 

Method of Photoelectron Holography Inversions



## XPH example: Mn on Ni(100)



Direct inversion of XPD volumes, using a model called "photelectron holography." The case of Mn atoms on a Ni(100) substrate is shown.

1Å

## Energy bands and Fermi Surfaces in solids



From Eli Rotenberg, Berkeley-Stanford Summer School 2001

## Angle-Resolved Photoemission Spectroscopy (ARPES): A way to directly measure band-structure



- Conservation of energy: determine energy position of bands
- Conservation of parallel momentum: determine momentum position
- Symmetry selection rules: determine parity of band

#### Measurement of energy bands by scanned-angle ARPES



From Eli Rotenberg, Berkeley-Stanford Summer School 2001

## Example: Cu(100)

## model





From Eli Rotenberg, Berkeley-Stanford Summer School 2001

# ARPES of a single crystal of PbS (galena)





## Mechanism of resonant photoemission

Valence Band





Transitions in Resonant Photoemission <u>Two (or more) paths to the same final state</u>



## X-ray Absorption Spectroscopy

Note the increases in absorption at characteristic energies.

